

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:  RUDOLF PETER MUIS ET AL.  Serial No.: 10/514,424  Filed: May 26, 2005  For: METHOD AND APPARATUS FOR APPLYING A LAYER OF A SECOND MATERIAL TO A LAYER OF A NANOCRYSTALLINE FIRST MATERIAL	Confirmation No.: 8641  Art Unit: 1792  Examiner: ROLLAND, Alex A.
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## REQUEST FOR RECONSIDERATION AFTER FINAL REJECTION

Mail Stop: AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed on December 4, 2009, please reconsider the above-identified application in view of the following remarks.

No extension of time or other fees are believed to be due, except as detailed in the attached documents. However, any extension of time necessary to prevent abandonment is hereby requested, and any fee necessary for consideration of this response is hereby authorized to be charged to Deposit Account Number 50-2613.

**Amendments to the Specification:** none.

**Amendments to the Claims:** none.

**Remarks:** begin on page 2 of this paper.